

# Spectroscopic Ellipsometry Studies of Optical Constants in Highly Excited Semiconductors



AVS 2022, Pittsburgh, PA

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<u>With</u>: Carola Emminger, Jose Menendez, Carlos A. Armenta, Melissa Rivero Arias, Jaden R. Love, Cesy M. Zamarripa, Sonam Yadav, Shirly Espinoza, Mateusz Rebarz, Martin Zahradnik, Jakob Andreasson

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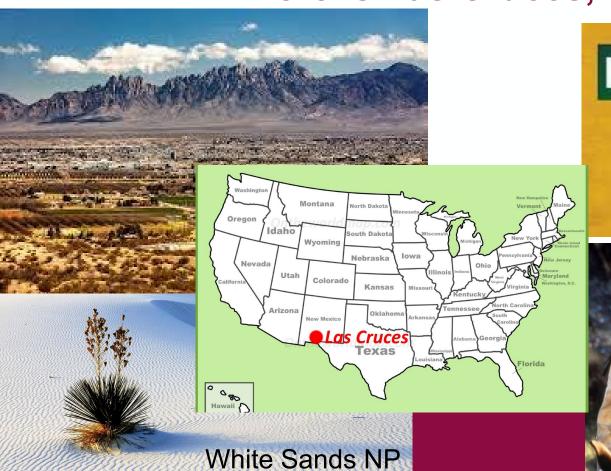


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College of Arts and Sciences, Department of Physics New Mexico State University, Las Cruces, NM, USA



#### Where is Las Cruces, NM???







#### **Problem Statement**

- (1) Achieve a <u>quantitative</u> understanding of absorption and emission processes.
- Our **qualitative** understanding of such processes is 50-100 years old,
- But **insufficient** for modeling of detectors and emitters.
- (2) How are optical processes affected by <a href="high-carrier concentrations">high carrier concentrations</a> (screening)?
- High carrier densities can be achieved with
  - In situ doping or
  - ultrafast lasers or
  - high temperatures.
- Goal: CMOS-integrated mid-infrared camera (thermal imaging with a phone).
- Future: How are optical processes affected by an electric field (pin diode or thin layer)?



#### Intensity of Optical Absorption by Excitons

R. J. Elliott

Phys. Rev. **108**, 1384 – Published 15 December 1957

Article References Citing Articles (1,780) PDF Export Citation

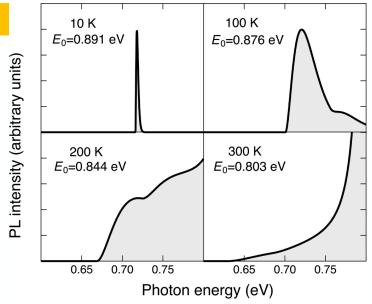
#### **ABSTRACT**

The intensity of optical absorption close to the edge in semiconductors is examined using band theory together with the effective-mass approximation for the excitons. Direct transitions which occur when the band extrema on either side of the forbidden gap are at the same  $\mathbf{K}$ , give a line spectrum and a continuous absorption of characteristically different form and intensity, according as transitions between band states at the extrema are allowed or forbidden. If the extrema are at different  $\mathbf{K}$  values, indirect transitions involving phonons occur, giving absorption proportional to  $(\Delta E)^{\frac{1}{2}}$  for each exciton band, and to  $(\Delta E)^2$  for the continuum. The experimental results on  $\mathrm{Cu}_2\mathrm{O}$  and  $\mathrm{Ge}$  are in good qualitative agreement with direct forbidden and indirect transitions, respectively.

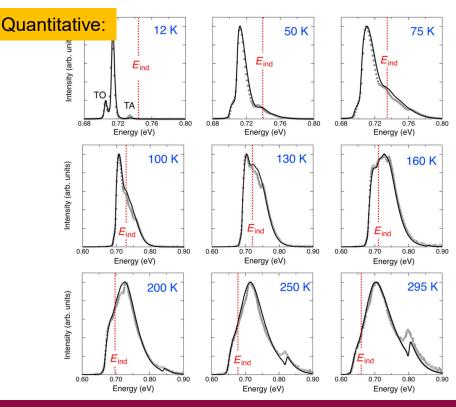
Received 9 April 1957

#### **Example 1: Photoluminescence in Germanium**

Qualitative:

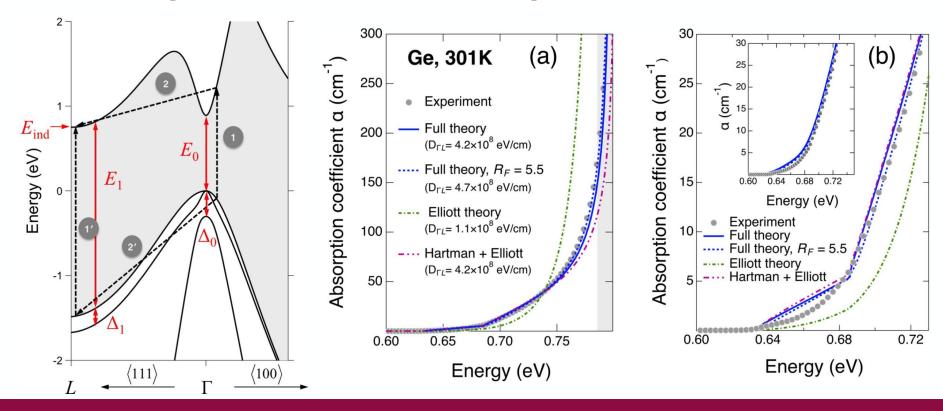


Roosbroeck-Shockley equation (PR **94**, 1558, 1954). **Complete failure above 200 K and at RT.** 





#### **Example 2: Indirect Absorption in Germanium**



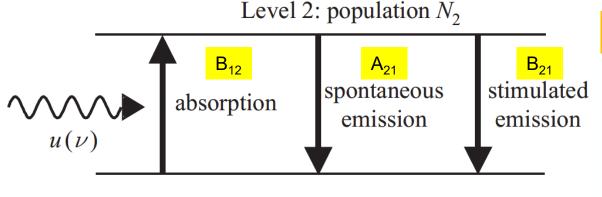


## **Optical Constants of Highly Excited Semiconductors**

- Einstein coefficients, Fermi's Golden Rule, Elliott-Tanguy excitons
- Direct gap absorption in germanium from 10 to 800 K
- Optical constants of highly excited semiconductors
  - Direct gap absorption in InSb from 10 to 800 K
  - Optical constants of highly excited germanium (femtosecond ellipsometry at ELI Beamlines in Prague)
- Conclusion and Outlook



#### **Einstein Coefficients**



Level 1: population  $N_1$ 

In equilibrium: N<sub>1</sub>, N<sub>2</sub> constant. Absorption and emission balance.

Black-body radiation  $u(\hbar\omega)$ 

$$B_{12}N_1u(\hbar\omega) = A_{21}N_2 + B_{21}N_2u(\hbar\omega)$$

One coefficient is sufficient:

$$g_1 B_{12} = g_2 B_{21}$$

$$A_{21} = \frac{2\hbar\omega^3}{\pi c^3} B_{21}$$

Use Fermi's Golden Rule to calculate B<sub>12</sub>



#### Fermi's Golden Rule: Tauc Plot

#### Direct band gap absorption

$$\frac{1}{\tau} = \frac{2\pi}{\hbar} \int_{i,f} |\langle f | H_{eR} | i \rangle|^2 \delta \left( E_f - E_i - \hbar \omega \right) = \frac{2\pi}{\hbar} |\langle f | H_{eR} | i \rangle|^2 g_{fi}(\hbar \omega) \quad \text{Joint DOS}$$

$$\langle f|H_{eR}|i\rangle = \frac{e}{m_0} \langle f|\overrightarrow{p}|i\rangle \cdot \overrightarrow{A}_0$$

Use  $\mathbf{k} \cdot \mathbf{p}$  matrix element P:  $E_P = 2P^2/m_0$ 

Use 
$$\mathbf{k} \cdot \mathbf{p}$$
 matrix element  $P$ :  $E_P = 2P^2/m_0$ 

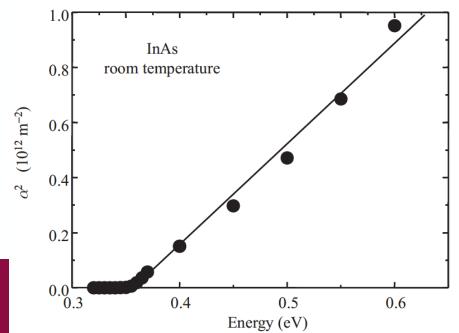
$$\varepsilon_2(\hbar\omega) = \frac{e^2\sqrt{m_0}\mu^{\frac{3}{2}}}{3\pi\sqrt{2}\varepsilon_0\hbar} \frac{E_P\sqrt{E_0}}{(\hbar\omega)^2} \sqrt{\frac{\hbar\omega}{E_0}} - 1$$

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Fox, Chapter 3

constant k·p matrix element

$$\frac{\pi}{2} |\langle f | H_{eR} | i \rangle|^2 g_{fi}(\hbar \omega)$$
 Joint DOS



#### Fermi's Golden Rule: Tauc Plot

#### Direct band gap absorption

$$\frac{1}{\tau} = \frac{2\pi}{\hbar} \int_{i,f} |\langle f|H_{eR}|i\rangle|^2 \delta(E_f - E_i - \hbar\omega) = \frac{2\pi}{\hbar} |\langle f|H_{eR}|i\rangle|^2 g_{fi}(\hbar\omega)$$

$$\langle f|H_{eR}|i\rangle = \frac{e}{m_0} \langle f|\vec{p}|i\rangle \cdot \vec{A}_0$$
Use  $\mathbf{k} \cdot \mathbf{p}$  matrix element  $P$ :  $E_p = 2P^2/m_0$ 

$$\varepsilon_2(\hbar\omega) = \frac{e^2 \sqrt{m_0} \mu^{\frac{3}{2}}}{3\pi\sqrt{2}\varepsilon_0 \hbar} \frac{E_p \sqrt{E_0}}{(\hbar\omega)^2} \sqrt{\frac{\hbar\omega}{E_0} - 1}$$

$$\frac{\hbar\omega}{2.5}$$
The Tauc plot is wishful thinking.

No linear region:
Broadening.
1/E<sup>2</sup> denominator.
excitons

Melissa Rivero Arias

0.8

0.9

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InAs (300 K) 0.5 Linear Fit Dixon&Ellis 1961 0.0 0.1 0.2 0.0 Photon energy (eV)

1/E<sup>2</sup> denominator.

The Tauc plot is

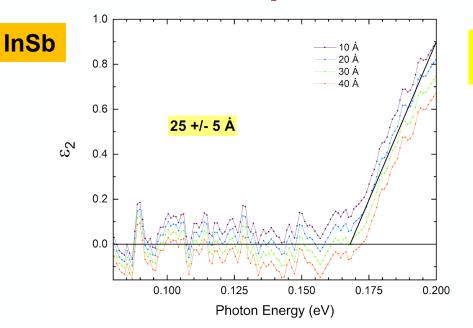
wishful thinking.

No linear region:

Broadening.

excitons

#### **Practical Tip: Oxide or Surface Correction**



Jellison-Sales Method for Transparent Glasses:
How thick is the surface region?

Optical constants for anodic oxide of InSb:  $\epsilon_{\text{m}}{\approx}3.8$ 

Mattausch, PRB **23**, 1896 (1981). Zollner, APL **63**, 2523 (1993).

Below the band gap,  $\varepsilon_2$  must be exactly zero for a bulk insulator (not positive, not negative). This method requires a compensator to measure  $\Delta$  exactly near 0 or 180 degrees. (Also change JAW software settings to allow negative  $\varepsilon_2$  values.)

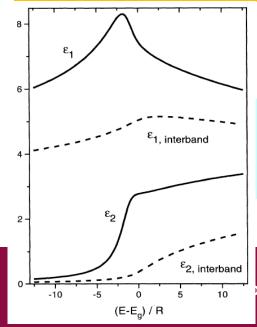


## **Elliott-Tanguy Exciton Absorption**

Direct band gap absorption

Excitonic binding energy:  $R=R_H \times \mu_h/\epsilon_s^2$ 

$$\varepsilon_{2}(\hbar\omega) = \frac{e^{2}\sqrt{m_{0}}\mu^{\frac{3}{2}}}{3\pi\sqrt{2}\varepsilon_{0}\hbar}\frac{E_{P}\sqrt{R}}{(\hbar\omega)^{2}}\left[\sum_{n=1}^{\infty}\frac{4\pi R}{n^{3}}\delta\left(\hbar\omega - E_{0} + \frac{R}{n^{2}}\right) + \frac{2\pi H(\hbar\omega - E_{0})}{1 - \exp\left(-2\pi\sqrt{R/\hbar\omega - E_{0}}\right)}\right]$$

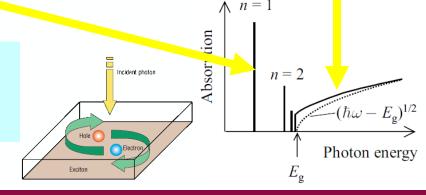


bound excitons

exciton continuum enhancement

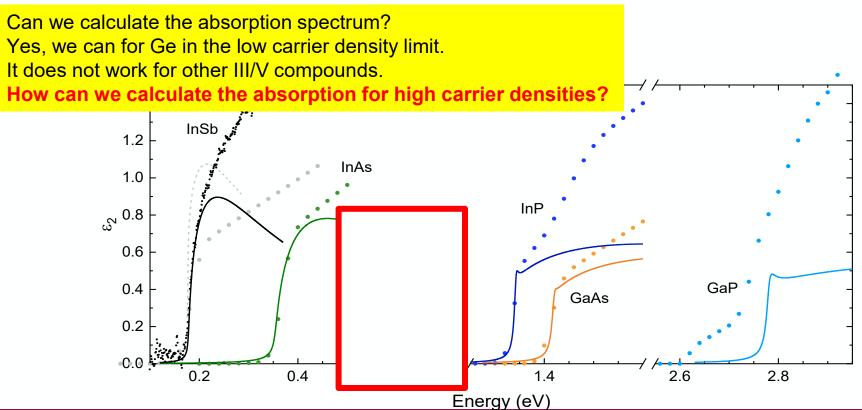
Tanguy's contributions:

- Add Lorentzian broadening
- Kramers-Kronig transform to get the real part.



R. J. Elliott, Phys. Rev. **108**, 1384 (1957). e the Future. Christian Tanguy, Phys. Rev. Lett. **75**, 4090 (1995) + (E)

#### Calculation of Absorption Spectrum from k.p Theory

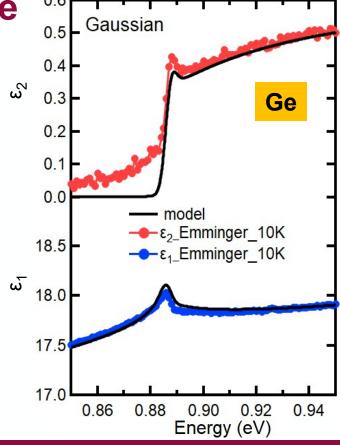




## Elliott-Tanguy theory applied to Ge

- Fixed parameters:
- Electron and hole masses (temperature dependent)
- Excitonic binding energy R
- Amplitude A (derived from matrix element P)
- Adjustable parameters:
- Broadening Γ: 2.3 meV
- Band gap E<sub>0</sub>
- Linear background  $A_1$  and  $B_1$  (contribution from  $E_1$  to real part of  $\varepsilon$ )

Quantitative agreement



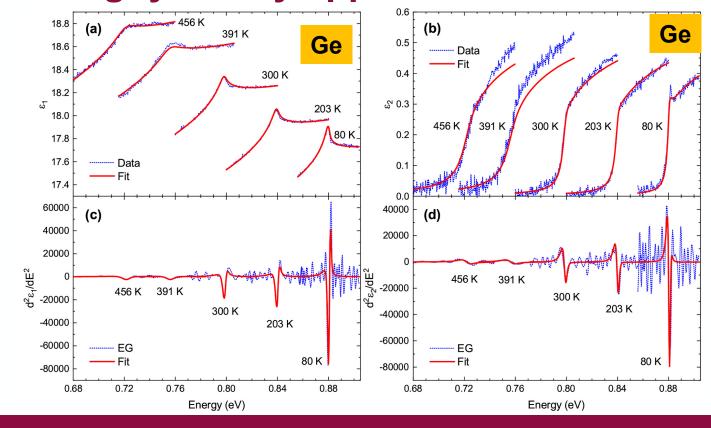
#### Elliott-Tanguy theory applied to Ge

# Good agreement at low temperatures.

Model also describes second derivatives.

#### **Potential problems:**

- Matrix element kdependent
- Nonparabolicity
- Resonant indirect absorption
- ??? at high T.





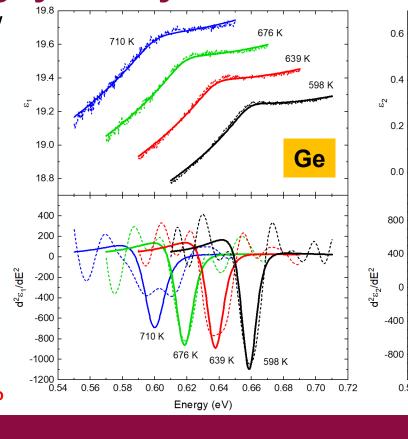
#### Elliott-Tanguy theory: Problems for Ge at high T

Good agreement at low temperatures.

Model also describes second derivatives.

#### **Potential problems:**

- Matrix element kdependent
- Nonparabolicity
- Resonant indirect absorption
- ??? at high T.
- Measurement error ??





0.58

0.60

Ge

710 K 676 K

0.62

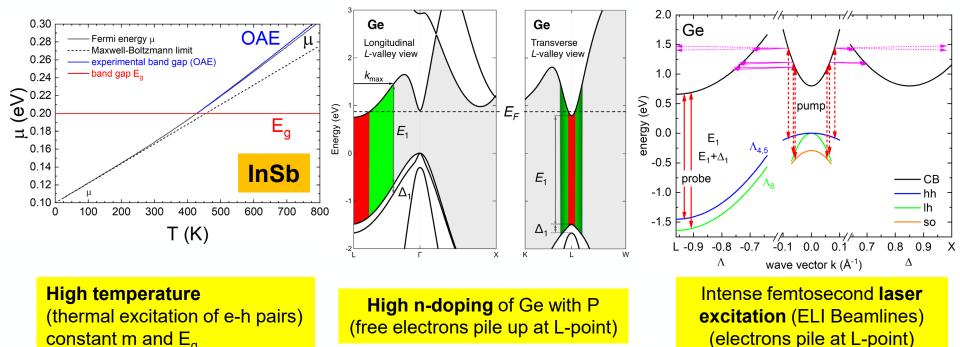
Energy (eV)

0.70

0.68

0.66

## **Optical Absorption at High Carrier Densities**



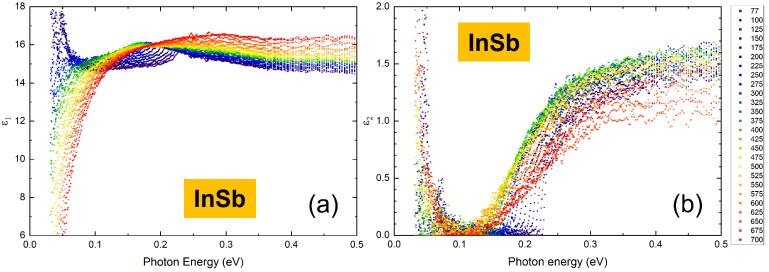
Rivero, JVSTB 41, 022203 (2023)

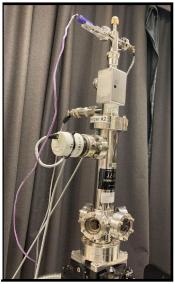
Xu et al., PRL **118**, 267402 (2017)

Espinoza, APL **115**, 052105 (2019)



#### (1) Dielectric function of InSb from 80 to 800 K





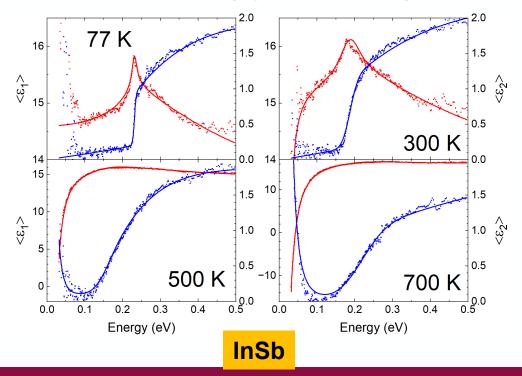
- Band gap changes with temperature (but only below 500 K).
- Amplitude reduction at high temperatures (Pauli blocking, bleaching)
- Drude response at high temperatures (thermally excited carriers).
- Depolarization artifacts at long wavelengths (below 300 K).

Woollam FTIR-VASE cryostat with CVD diamond windows

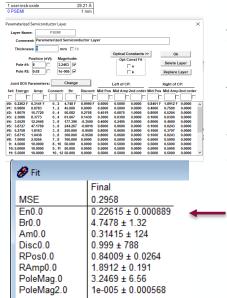


## Band gap analysis for InSb

How does the band gap of InSb change with temperature?



#### **Parametric-Semiconductor Model:**



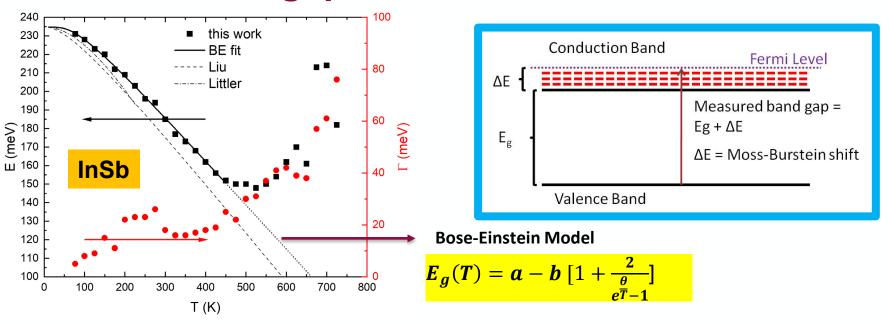
Also vary "shape parameters".

Asymmetric peak shape poorly described.

Try Tanguy oscillator for excitonic line shape.



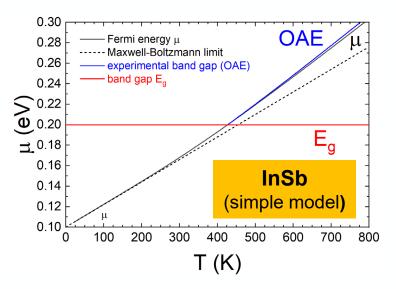
#### Band gap of InSb from 80 to 800 K



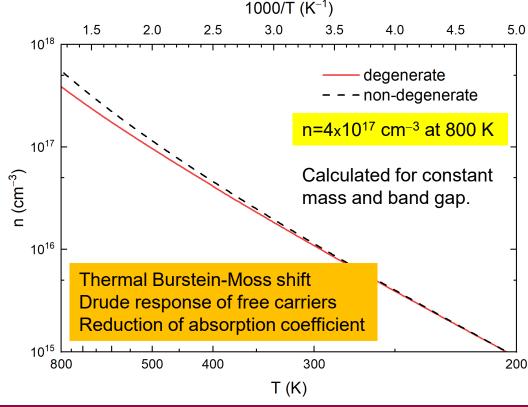
- Band gap changes with temperature (but only below 500 K)
- Described by Bose-Einstein model below 500 K: Logothetidis, PRB 31, 947 (1985).
- No redshift above 500 K: Thermal Burstein-Moss shift



#### Thermal excitations of electron-hole pairs in InSb



k<sub>B</sub>T=E<sub>g</sub>/4 at 600 K
Fermi level above the conduction band edge above 450 K.
(Calculated for constant m and E<sub>g</sub>)

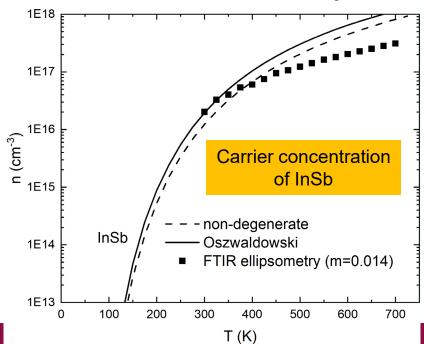


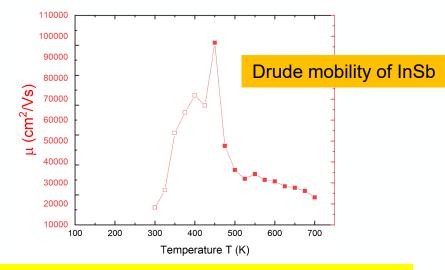


#### Carrier concentration and mobility from 80 to 800 K

To model the **Drude response**, we make some really simple assumptions:

- Parabolic bands (ignore non-parabolicity)
- Effective mass constant m<sub>e</sub>=0.014 (independent of temperature)





Reasonable agreement with Hall measurements. Large errors below 400 K (depolarization).



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Oswaldowski/Zimpel, J. Phys. Chem. Solids **49**, 1179 (1988). D. L. Rode, Phys. Rev. B **3**, 3287 (1971).

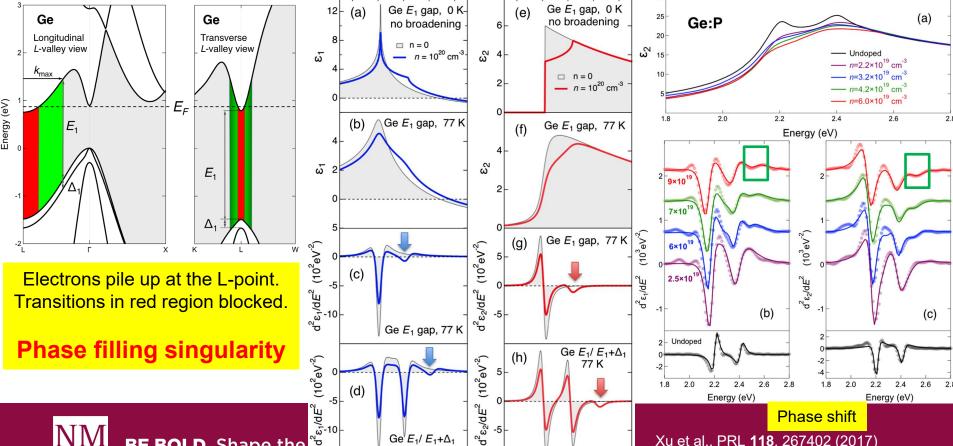
#### Required model improvements: Screened Excitons

$$\varepsilon_{2}(E) = \frac{2\pi A\sqrt{R}}{E^{2}} \left\{ \sum_{n=1}^{\sqrt{g}} \frac{2R}{n} \left( \frac{1}{n^{2}} - \frac{n^{2}}{g^{2}} \right) \delta\left[ E - E_{0} + \frac{R}{n^{2}} \left( 1 - \frac{n^{2}}{g} \right)^{2} \right] + \frac{\sinh(\pi g k) H(E - E_{0})}{\cosh(\pi g k) - \cosh\left(\pi g \sqrt{k^{2} - \frac{4}{g}}\right)} \right\} [f_{h}(E) - f_{e}(E)]$$

- Absorption by screened excitons (Hulthen potential)
- Kramers-Kronig transform following Tanguy (includes broadening  $\Gamma$ )
- Degenerate Fermi-Dirac statistics to calculate  $f_h$  and  $f_e$ .
- Two terms for light and heavy excitons
- Non-parabolicity and temperature-dependent mass included from k.p theory
- k-dependent matrix element P.
- Screening parameter  $g=12/\pi^2 a_R k_{TF}$  (large: no screening)
- Only two free parameters: Band gap  $E_0$  and broadening  $\Gamma$
- Amplitude A and exciton binding energy R from k.p theory and effective masses



## (2) Highly doped Ge (n-type, with phosphorus)



2.0

2.2 2.4 2.6 Energy (eV)

 $Ge^{\parallel}E_1/E_1+\Delta_1$ 

2.0 2.2 2.4 2.6

Energy (eV)

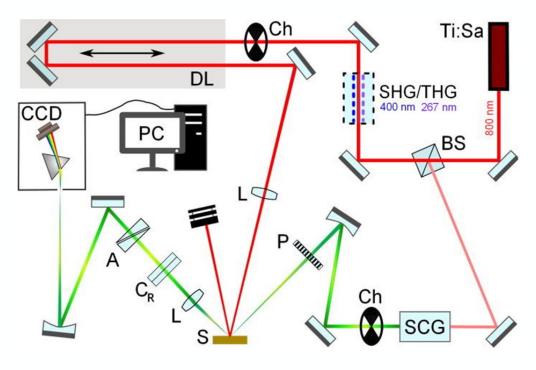


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Xu et al., PRL 118, 267402 (2017) Xu et al., JAP **125**, 085704 (2019)

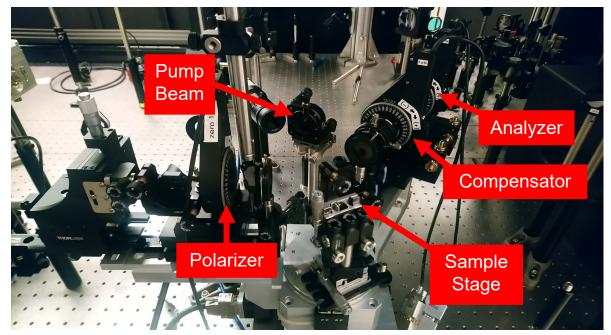
25

## (3) Set-up: Femtosecond pump-probe ellipsometry



- Ch: Chopper (500 Hz, 250 Hz)
- A: Analyzer
- P: Polarizer
- C<sub>R</sub>: Rotating compensator
- L: Lens
- S: Sample
- DL: Delay Line (~6.67 ns pump-probe delay and 3 fs resolution)
- BS: Beam splitter
- SHG/THG: 2<sup>nd</sup>/3<sup>rd</sup> harmonic generation
- SCG: Super-continuum generation
- CCD: Charge-coupled device detector

#### **Set-up: Femtosecond pump-probe ellipsometry**



#### Rotating compensator ellipsometer:

Compensator was rotated in steps of 10° for a total of 55-65 angles.

Probe beam of 350-750 nm at 60° incidence angle.

P-polarized pump beam: 35 fs pulses of 800 nm wavelength at 1 kHz repetition rate.

Delay time from -10 to 50 ps.

Time resolution of about 500 fs.

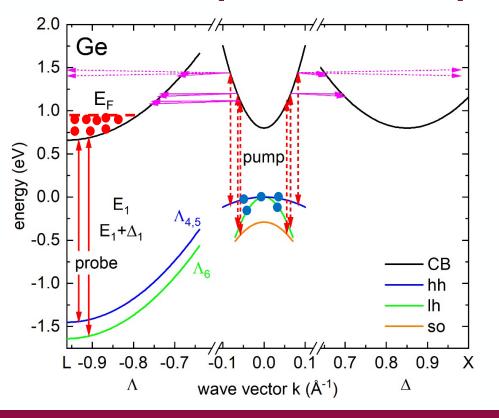


## ELI Beamlines: ELI ERIC. Dolní Břežany (near Prague)

Second user call due **April 25<sup>th</sup>**, **2023**: https://up.eli-laser.eu/Contact Shirly Espinoza: shirly.espinoza@eli-beams.eu



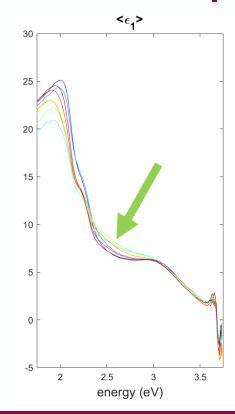
#### Ultrafast processes in photoexcited Germanium

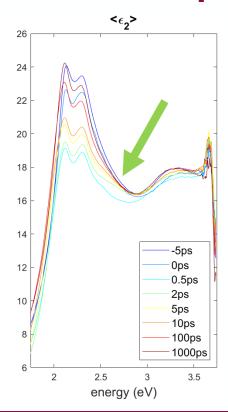


- 1.55 eV pump beam creates N=10<sup>21</sup> cm<sup>-3</sup> electron-hole pairs near Γ-point. 9 mW power.
- · Heavy, light, split-off bands.
- Ignore diffusion (for 1.55 eV pump).
- Ignore Auger recombination.
- Thermalization: Fermi-Dirac distribution
- Intervalley scattering:  $\Gamma \rightarrow X \rightarrow L$
- Electrons accumulate at L.
- Holes remain near Γ.
- Electrons at L block E₁ and E₁+∆₁ transitions (Fermi-level singularity)
- Bandgap renormalization: redshift expected
- Lattice heating (25 K): redshift
- Exciton screening



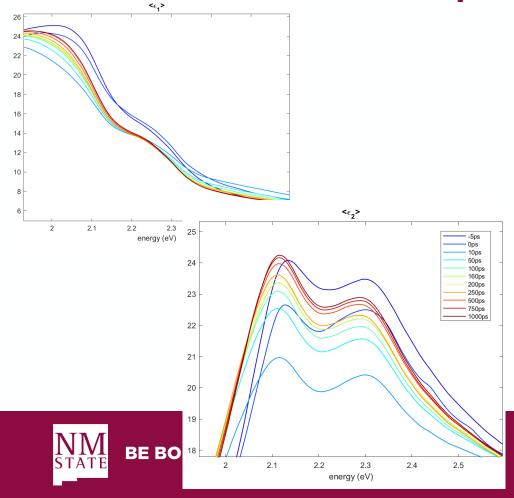
#### Ultrafast processes in photoexcited Germanium





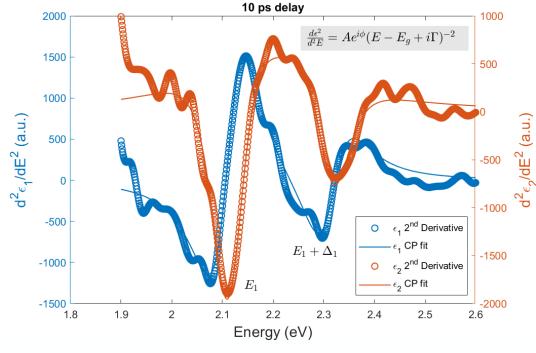
- 1.55 eV pump beam creates N= $4x10^{21}$  cm<sup>-3</sup> electron-hole pairs near  $\Gamma$ -point.
- The E₁ and E₁+∆₁ peaks decrease within the first two picoseconds and then recover:
   Band filling, excitonic screening followed by diffusion, Auger, and radiative recombination.
- Maybe a Fermi level singularity near 2.6 eV.
- Detailed modeling is required (Tanguy 2-D excitonic line shapes, including Fermi level singularity.)

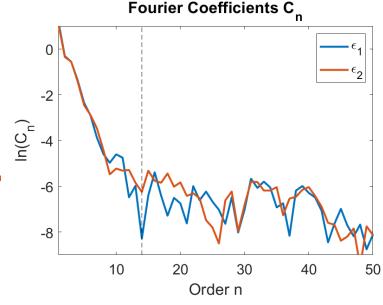
#### Ultrafast processes in photoexcited Germanium



- 1.55 eV pump beam creates N= $4x10^{21}$  cm<sup>-3</sup> electron-hole pairs near  $\Gamma$ -point.
- The E₁ and E₁+∆₁ peaks decrease within the first two picoseconds and then recover.
   (Band filling, excitonic screening followed by diffusion, Auger, and radiative recombination)
- Maybe a Fermi level singularity near 2.6 eV.
- It looks like there is a redshift, but we need a line shape analysis with derivatives.

#### Derivative analysis: critical point parameters

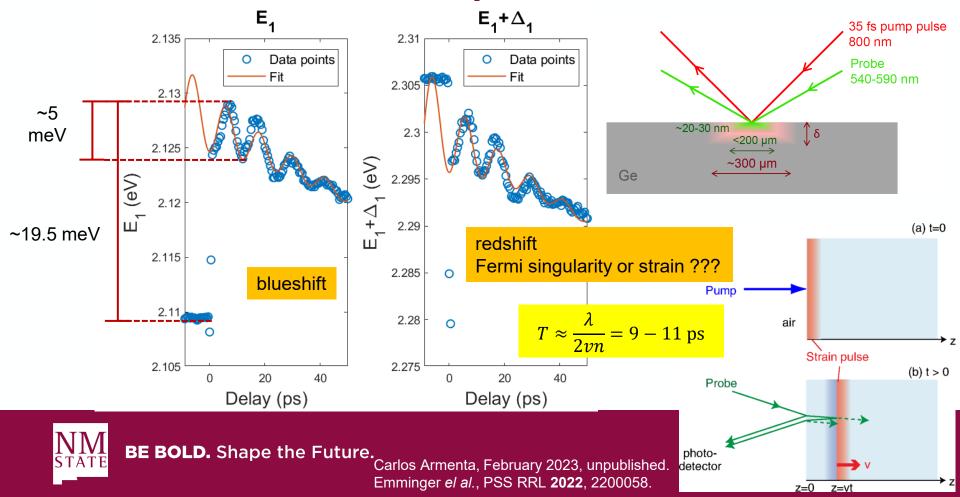




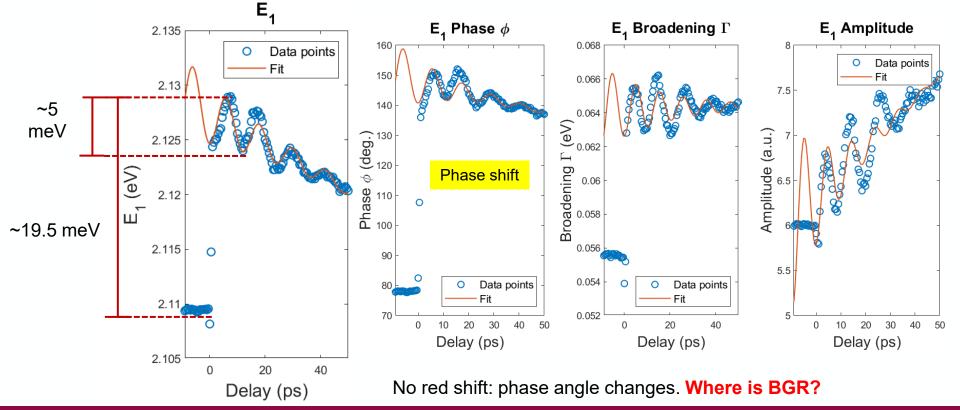
Extended Gauss filter
Filter width determined from Fourier coefficients



#### Coherent acoustic phonon oscillations



# Critical point parameters for $E_1$ and $E_1+\Delta_1$





#### **Conclusions**

- Quantitative modeling of low-density optical processes is possible with basic physics and matrix elements from k.p theory:
  - Photoluminescence in Ge
  - Indirect gap absorption in Ge
  - Direct gap absorption in Ge at low T
  - More work is needed at high temperatures and for materials other than Ge.
- High carrier excitations:
  - High electron doping density in Ge
  - Thermal excitation of electron-hole pairs in InSb
  - Femtosecond laser generation of electron-hole pairs in Ge (ELI Beamlines)
  - Experimental data and qualitative explanations exist
- We need more experiments and more detailed theory and simulations.





# Thank you!

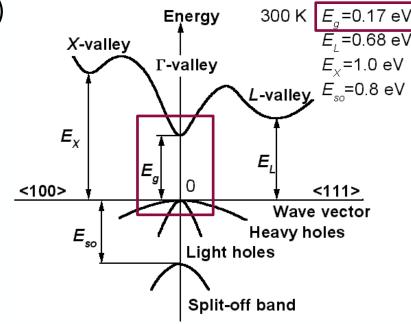
# **Questions?**

## Direct band gap of InSb from 80 to 700 K

Measurement of the dielectric function of bulk InSb from 80 to 700 K near the direct band gap ( $E_0$ )



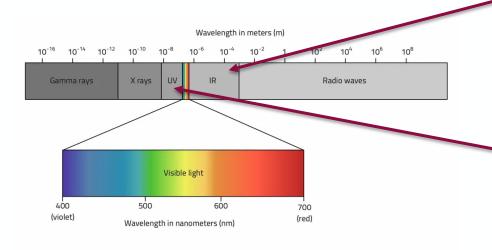
Bulk InSb: Commercial (MTI), (100) orientation, undoped, n-type, rough back side

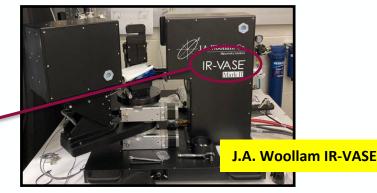




# Ellipsometry from 190 nm to 40,000 nm

Two different instruments are used for measurements from the mid-infrared to the deep ultraviolet spectral range.









# Temperature-dependent ellipsometry: 80-700 K

Using FTIR spectroscopic ellipsometry in an ultra-high vacuum (UHV) cryostat with CVD diamond windows (Janis ST-400, Diamond Materials GmbH, Freiburg).

Why diamond? Large transparency range and good vacuum seals, but expensive

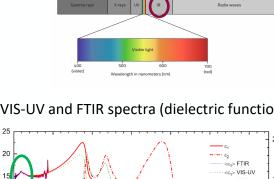
and high reflection losses.



J.A. Woollam IR-VASE

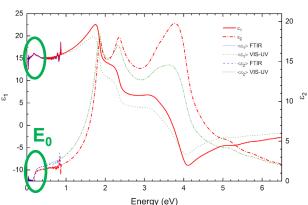
**Cryostat with CVD** diamond windows

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Energies: 30-40 meV to 1 eV

VIS-UV and FTIR spectra (dielectric functions) After oxide correction (25 Å)



Compare: Aspnes, PRB 27, 985 (1983) Logothetidis, PRB 31, 947 (1985). Schaefer, JAP 127, 165705 (2020).

SZ, Adv. Opt. Technol. 11, 117 (2022).

# InSb (100) sample preparation (cleaning)

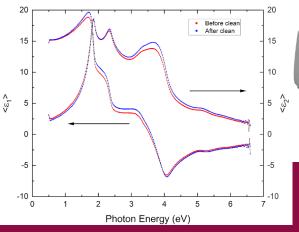
The InSb (100) sample was cleaned using water and isopropanol on the ultrasonic cleaner for 15 min on each to remove organic layers before the temperature dependent ellipsometry measurements.

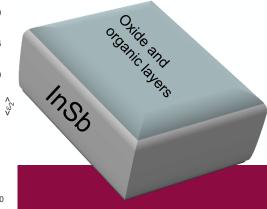
Also: Anneal sample at 450 K in UHV overnight (degas)

Not used: BrM, HCl-methanol (Aspnes/Studna 1983)



	Oxide Thickness (Å)
Before Clean	28.2
After Clean	22.5

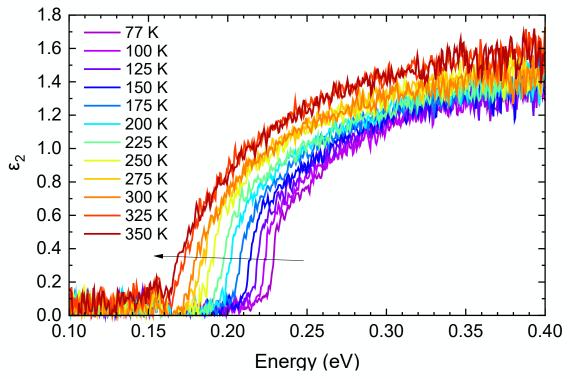






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## InSb (100): Initial attempt was promising



Multiple experimental issues:

- InSb sample cracks, melts, reacts with the Cu sample holder.
- Adhesive (carbon nanoparticles, silver paint) expands, evaporates, redeposits on the windows.
- Beam larger than sample: Depolarization from sample holder reflections.
- Black-body radiation, heat shield.
- Cryostat leaks, thermocouple breaks.

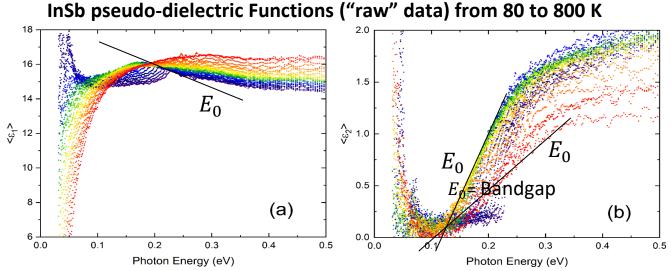
Initial result: Clear redshift with increasing temperature (up to 450 K).

Strange things happen above 450 K.



## Data and oxide corrections (4 years later)





- Band gap reduced with increasing temperature (but only below 500 K)
- Drude response at high temperatures (thermally excited carriers)
- Depolarization artifacts at long wavelengths (below 300 K)



• 77

300

525 550

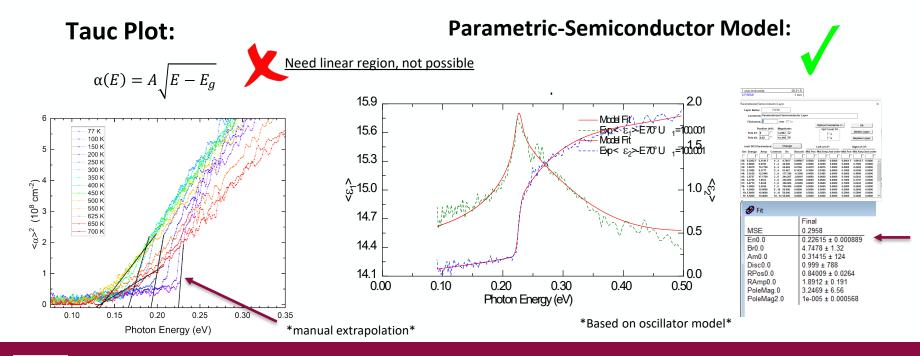
600

625 650

675 700

# **Band gap analysis**

How does the band gap of InSb change with temperature?





#### **Conclusions**

- Dielectric function of InSb measured from 80 to 700 K (with oxide correction of 25±5 Å)
- Band gap is difficult to determine from a Tauc plot.
- Parametric semiconductor model shows great results for the band gap.
- Band gap shrinks with increasing temperature, but only up to 500 K.
- Band gap stays constant near 550 K and then increases again to 700 K.
- Drude tail due to thermal excitation of electron-hole pairs.
- Carrier concentration and mobility is reasonable (compared to Hall measurements).
- Detailed modeling requires Tanguy-Elliott theory of absorption by screened excitons, non-parabolicity, degenerate Fermi-Dirac statistics, k.p theory (in progress).
- InSb would behave as a topological insulator above melting point. Not possible.



# Sad ending

- Unfortunately, the InSb sample melted at 750 K, but melting point is 800 K...
- Cannot become a topological insulator because it melts.

**Before** 



After



#### **Future work:**

Repeat experiment at high temperatures (below 750 K).

Increasing and decreasing temperature scans.

